

References:

1. K. C. Sharma, R. P. Sharma and J. C. Garg; *Jour. Phys. D: Appl. Phys.* 25, 1992, 1024.
2. T. Ishizaki, T. Ohtomo and A. Fuwa; *Jour. Phys. D: Appl. Phys.*, 37, 2004, 255.
3. K. C. Sharma, R. P. Sharma and J. C. Garg; *Ind. Jour. Pure and Appl. Phys.*, 28, 1990, 591.
4. F. Raoult, B. Fortin and Y. Colin; *Thin Solid Films*, 182, 1989, 1-14.
5. C. Baban, G. I. Rusu and P. Prepelita; *Jour. Optoelectro. Adv. Mater.*, 7(2), 2005, 817-821.
6. K. C. Sathyalatha, S. Uthanna and P. Jayaramareddy; *Thin Solid Films*, 174, 1989, 233-238.
7. P. K. Kalita, B. K. Sarma and H. L. Das; *Bull. Mater. Sci.*, 26(6), 2003, 613-617.
8. S. Gogoi and K. Barua; *Jpn. Jour. Appl. Phys.*, 18(12), 1979, 2233-2236.
9. K. C. Sarma, R. Sarma and J. C. Garg; *Jpn. Jour. Appl. Phys.*, 31, 1992, 742.
10. R. H. Bube; *Photoconductivity of Solids*, Wiley, N. Y., 1960, Chapter-7.
11. J. I. Pankove, *Optical Processes in Semiconductors*, New York, Dover Pub. Inc. 1971, 34.
